

Substitute for form 1449A/PTO (modified)  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (Use as many sheets as necessary)  OCT 02 2006 Page 1 of 1	Application Number	10/646093
	Filing Date	August 22, 2003
	First Named Inventor	Wolk, Martin B.
	Confirmation Number	
	Attorney Case Number	58626US002

U.S. Patent Documents					
Exam. Init.*	Cite No.	Document Number Doc. Number (Kind Code if Known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
/JW/	A1	US- 2001/000744 A1	05/03/2001	Wolk et al.	
/JW/	A2	US- 2003/124265 A1	07/03/2003	Bellmann et al.	
	A3	US-			
	A4	US-			
	A5	US-			
	A6	US-			
	A7	US-			
	A8	US-			

Foreign Patent Documents							
Exam. Init.*	Cite No.	Foreign Patent Document		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation (Check if yes)
		Ctry. Code	Number-KindCode (if known)				
/JW/	B1	EP	0 799 713 A	10/08/1997			
/JW/	B2	EP	0 920 385 A	06/09/1999			
	B3						
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	B7						

OTHER DOCUMENTS			
Exam. Init.*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	Translation (Check if yes)
/JW/	C1	Seong Take Lee et al., "A New Patterning Method for Full-Color Polymer Light-Emitting Devices: Laser Induced Thermal Imaging (LITI)" 2002 SID International Symposium Digest of Technical Papers, San Jose, CA: SID, US, vol. 33/2, May 2002 (2002-05), pages 784-787, XP001134318 *the whole document*	
	C2		
	C3		

*Examiner: /Joseph Williams/ (06/11/2007)	Date Considered: 06/11/2007
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